



41

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Hiromoto OHNO, et al.

Appln. No.: 10/088,306

Confirmation No.: 2926

Filed: March 18, 2002

For: **CLEANING GAS FOR SEMICONDUCTOR PRODUCTION EQUIPMENT**

RECEIVED

JUL 27 2004

TECHNOLOGY CENTER R3700

Docket No: Q60716

Group Art Unit: 3749

Examiner: Kathryn S. O Malley

RESPONSE TO RESTRICTION REQUIREMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Responsive to the outstanding Restriction Requirement of July 13, 2004, Applicant elects Group I, claims 1-22 (gas composition) for prosecution, without traverse. Applicants reserve the right to request rejoinder of method claims including all the limitations of any allowable product claim pursuant to MPEP §821.04. Applicants also reserve the right to file a Divisional Application directed to the non-elected subject matter.

The USPTO is directed and authorized to charge all required fees, except for the Issue Fee and the Publication Fee, to Deposit Account No. 19-4880. Please also credit any overpayments to said Deposit Account.

Respectfully submitted,

SUGHRUE MION, PLLC
Telephone: (202) 293-7060
Facsimile: (202) 293-7860

Abraham J. Rosner
Registration No. 33,276

WASHINGTON OFFICE

23373

CUSTOMER NUMBER

Date: July 23, 2004